

SWISSFEL, The X-ray Free Electron Laser at PSI

Hans-H. Braun on behalf of the SwissFEL team

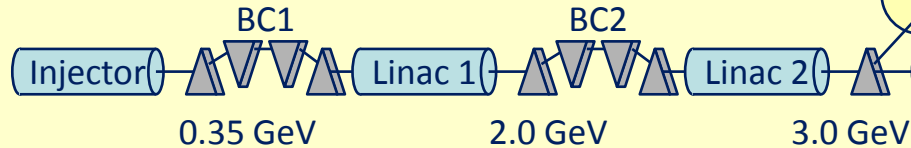
34th International Free Electron Laser Conference

Nara, August 26-31, 2012

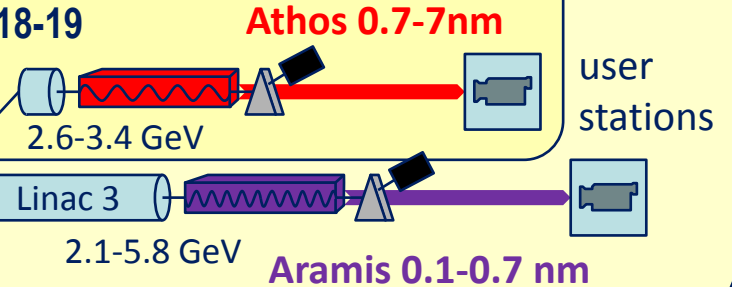


- Overview
- Injector Test Facility
- Progress with C-band main Linac
- Undulators

1st construction phase 2013-16



2nd construction phase 2018-19



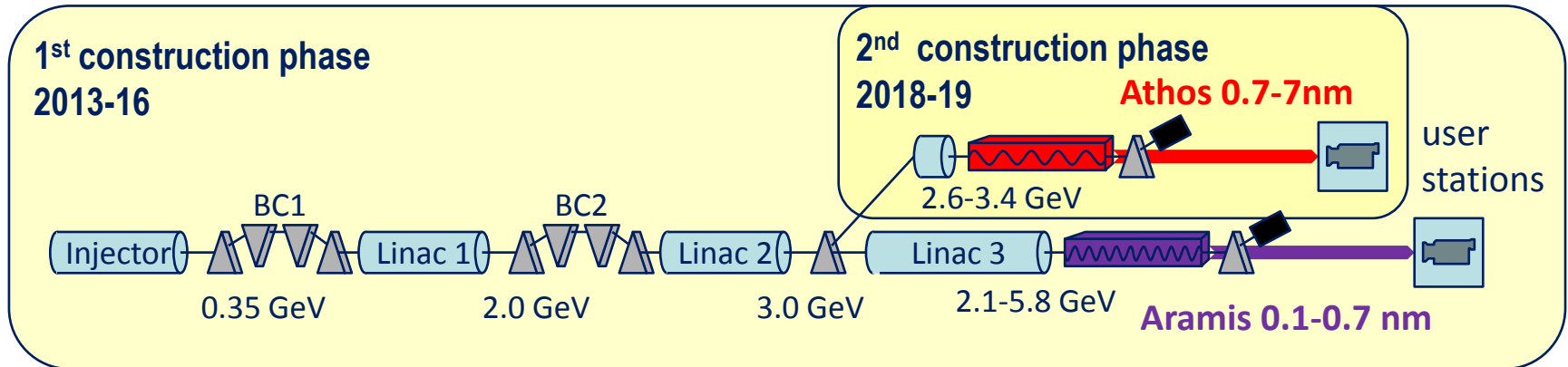
Aramis

1-7 Å hard X-ray FEL for **SASE with reservations for self seeded** operation,
In-vacuum, planar undulators with variable gap.
User operation from 2017

Athos

7-70 Å soft X-ray FEL for **SASE & self seeded** operation .
APPLE II undulators with variable gap and full polarization control.
User operation from 2019

Schedule



Advanced project
funding from
economic stimulus
package

Swiss government
finance period

Next finance period

2012	2013	2014	2015	2016	2017
component procurement accelerator and ARAMIS FEL				preparation ATHOS FEL	
preparatory work	building construction		Accelerator and ARAMIS FEL installation		commissioning
					friendly users

Injector

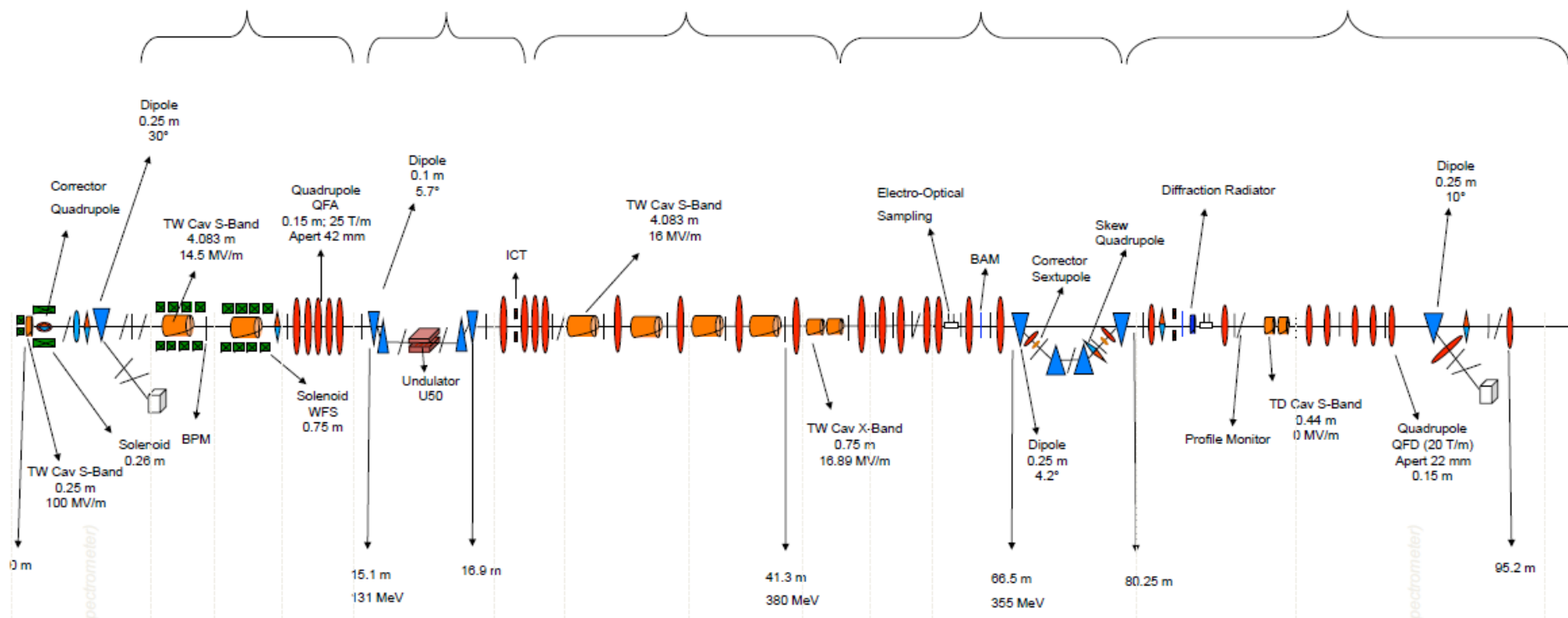
Booster 1

Laser Heater

Booster 2

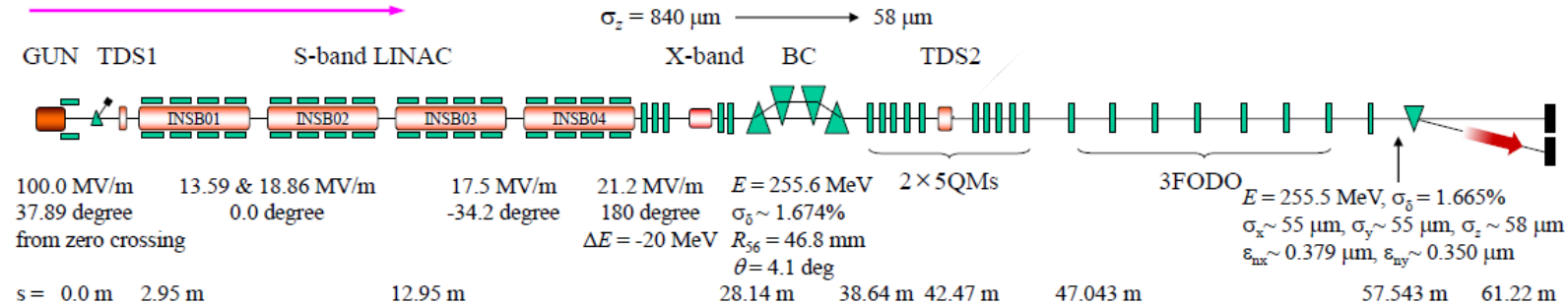
Bunch Compressor 1

Injector Diagnostic Section



SwissFEL injector Test facility

laser beam : $\sigma_{x,y} = 270 \mu\text{m}$, $\Delta T = 9.9 \text{ ps}$ (FWHM), rise & falling time = 0.7 ps
e-beams : $Q \sim 0.2 \text{ nC}$, $\epsilon_{\text{thermal}} = 0.195 \mu\text{m}$, $I_{\text{peak}} = 22 \text{ A}$



Injector building



Commissioning crew with first beam

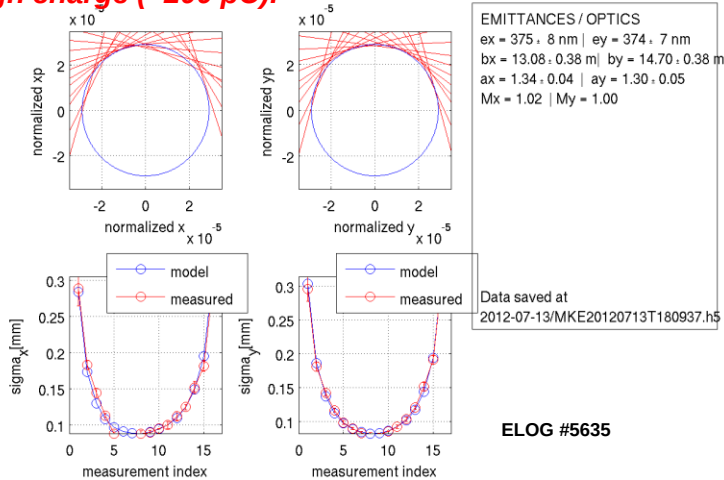


SwissFEL Injector Test Facility

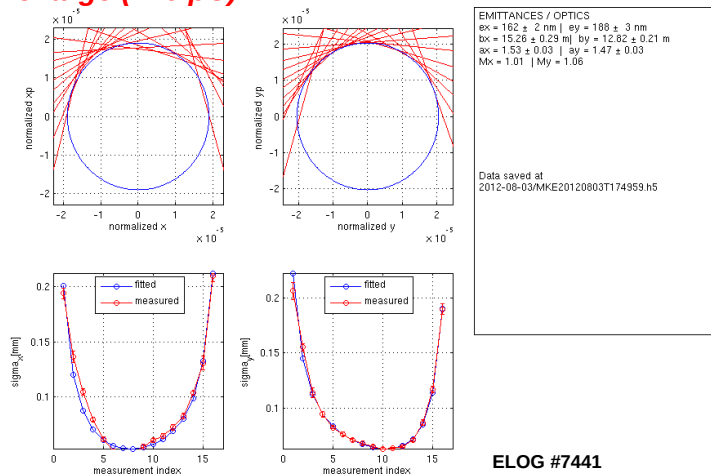
Emittance optimization (uncompressed beam)

Example measurements projected emittance (symmetrized single-quad scan)

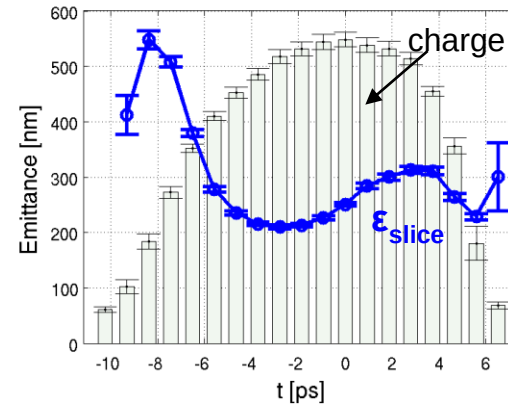
High charge (~200 pC):



Low charge (~10 pC):



Slice emittance measurement (200 pC)



CORE SLICE EMITTANCES / OPTICS
ex = 251 ± 4 nm
bx = 13.06 ± 0.30 m
ax = -2.17 ± 0.04
Mx = 1.26

PROJECTED EMITTANCES / OPTICS
ex = 320 ± 6 nm
bx = 13.84 ± 0.42 m
ax = -1.59 ± 0.06
Mx = 1.08

ELOG #5602

Key steps for optimization:

- Optimization gun solenoid (incl. corrector quads)
- Orbit correction in S-band structures (wakefields)
- Local correction of dispersion at observation point

Summary emittance measurements (uncompressed beam):

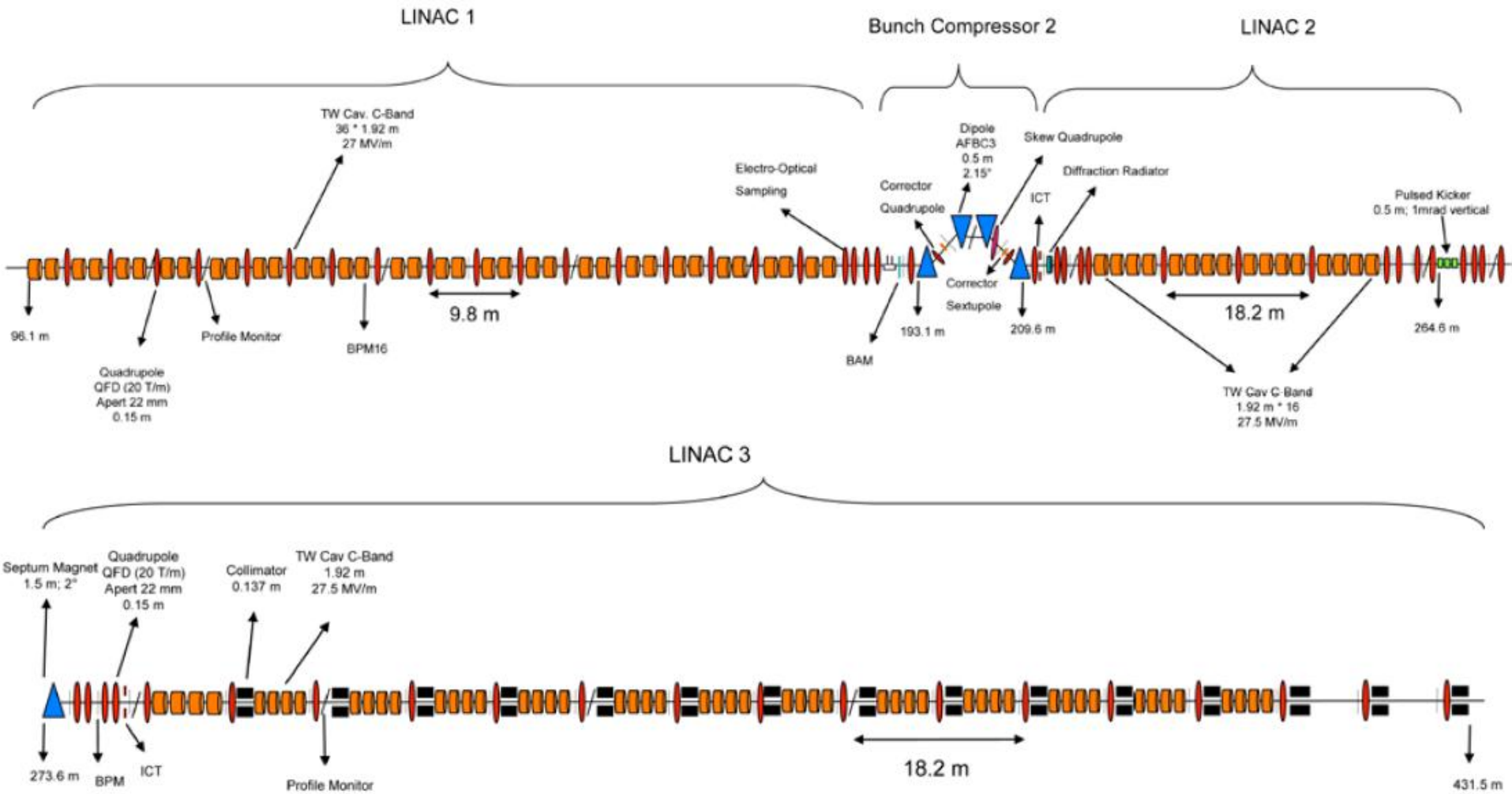
Measurement	σ_{laser} [mm]	$\epsilon_{n,x}$ [μm]	$\epsilon_{n,y}$ [μm]	$\epsilon_{n,\text{simulated}}$ [μm]	$\epsilon_{n,\text{required @undulator}}$ [μm]
<i>High-charge mode (~200 pC):</i>					
projected:	0.21	0.38	0.37	0.350	0.65
core slice:	0.21	0.25	—	0.330	0.43
<i>Low-charge mode (~10 pC):</i>					
projected:	0.10	0.16	0.18	0.096	0.25
core slice:	0.10	≤ 0.15*	—	0.080	0.18

*measurement limited by signal-to-noise ratio

Injector schedule

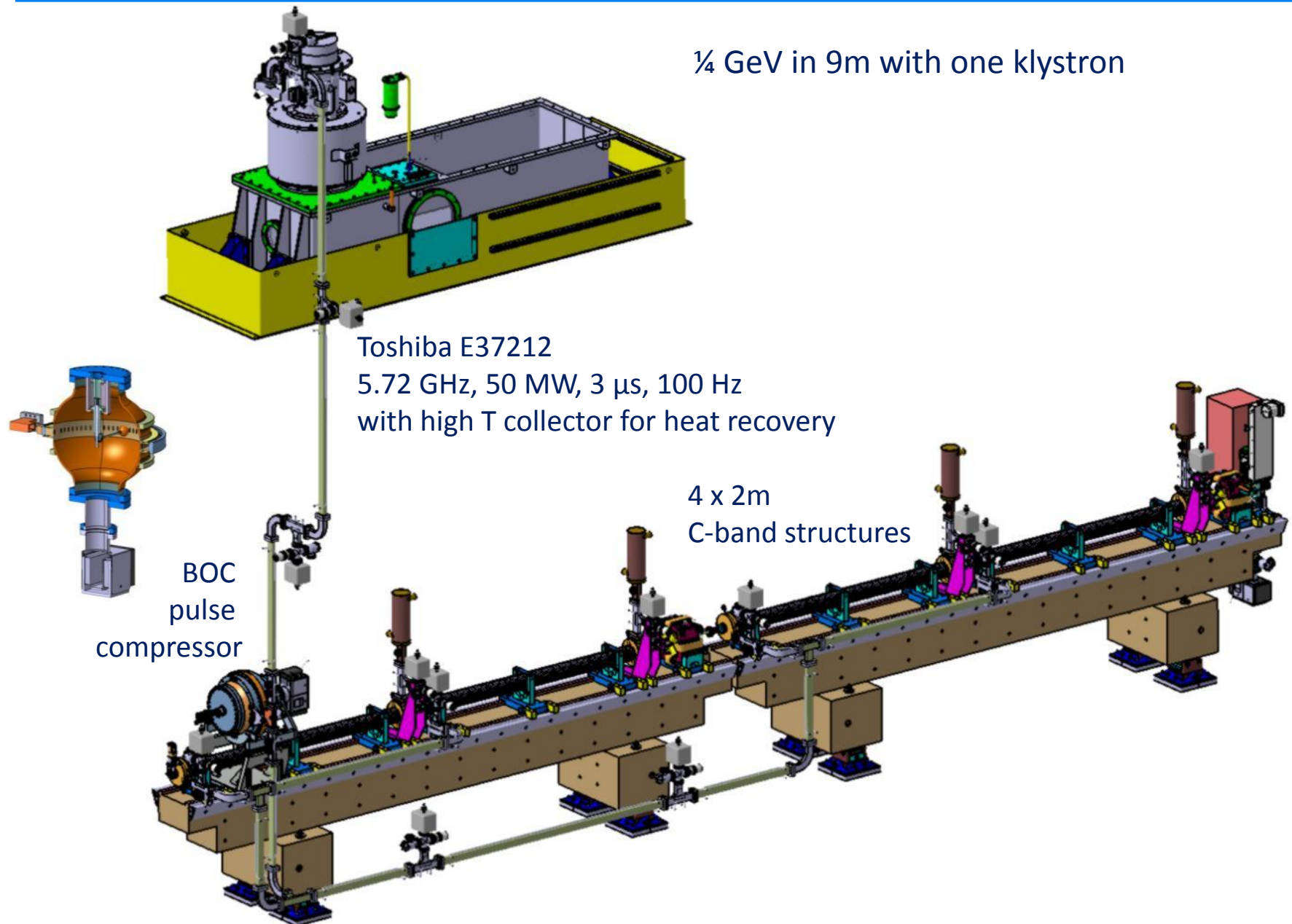
2012	2013	2014	2015	2016	2017		
Injector test facility Beam development and component tests			Moving into SwissFEL building	Injector	commissioning	Operation for linac and FEL commissioning	operation for friendly users

Linac



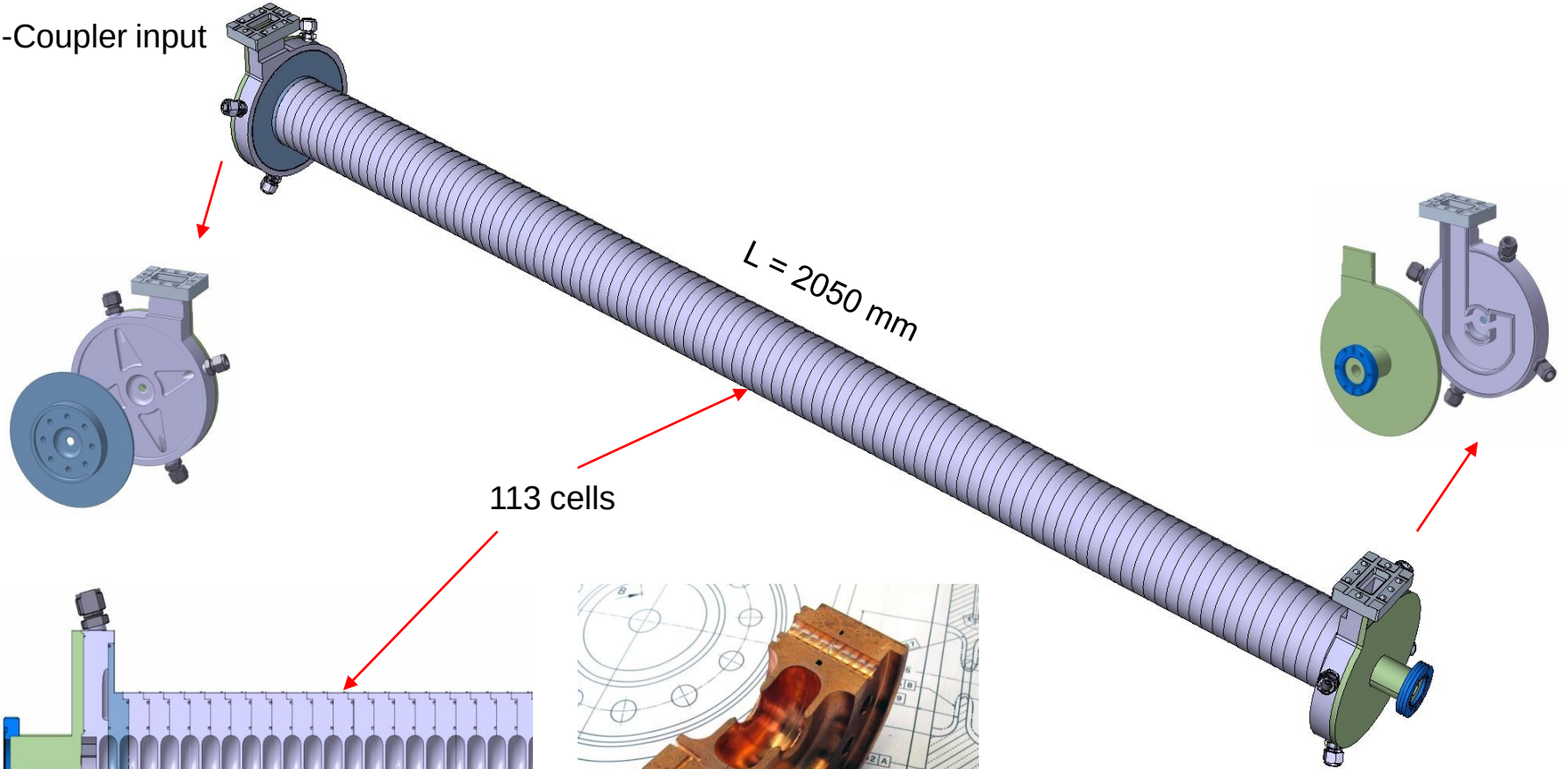
SwissFEL C-Band Linac Module

$\frac{1}{4}$ GeV in 9m with one klystron



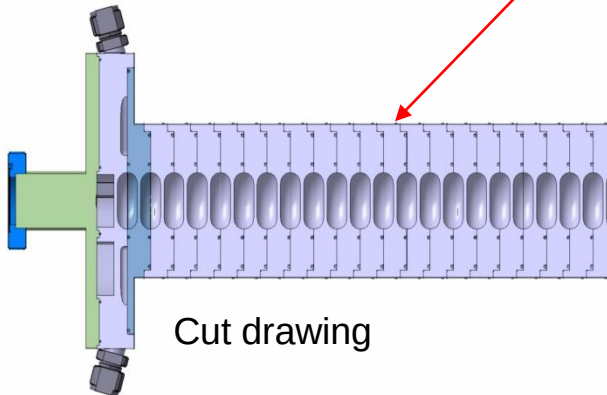
C-Band Structure

J-Coupler input

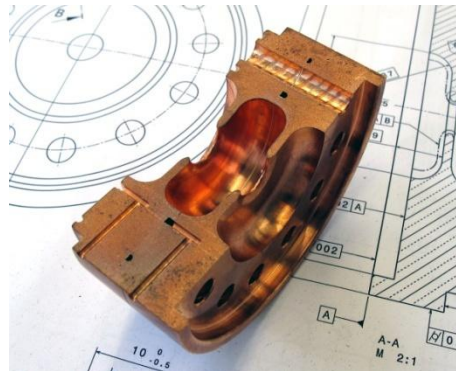


$L = 2050 \text{ mm}$

113 cells



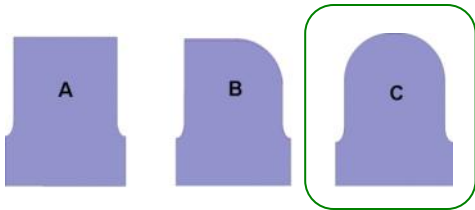
Cut drawing



J-Coupler output

cooling

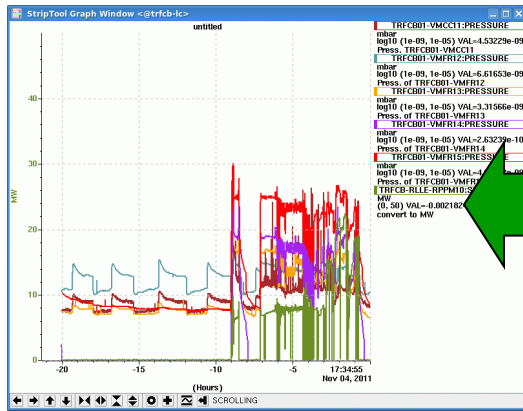
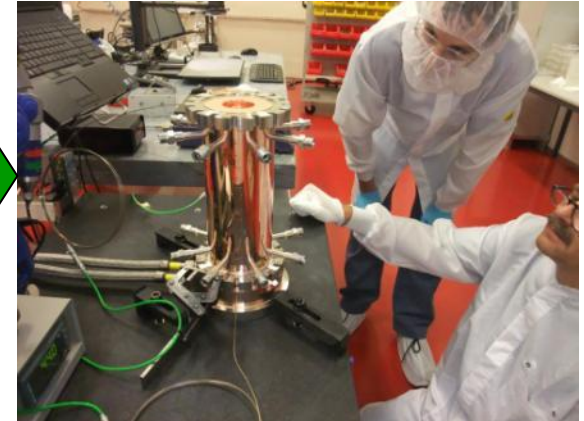
RF designs



mech. design & UP machining



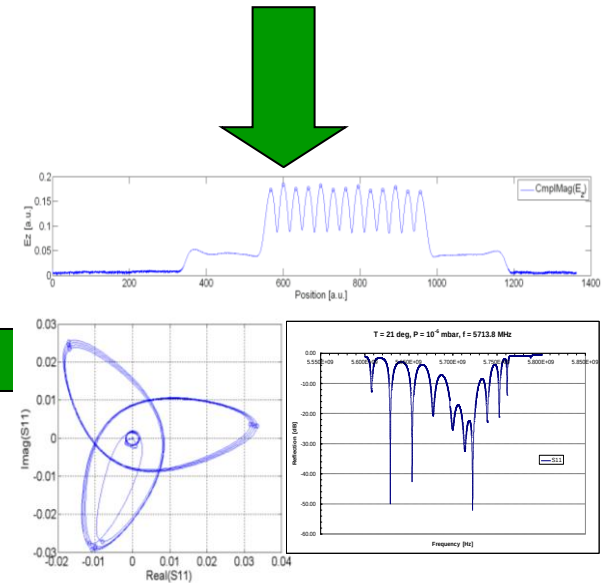
Assembly & brazing



HP RF processing



HP RF set-up

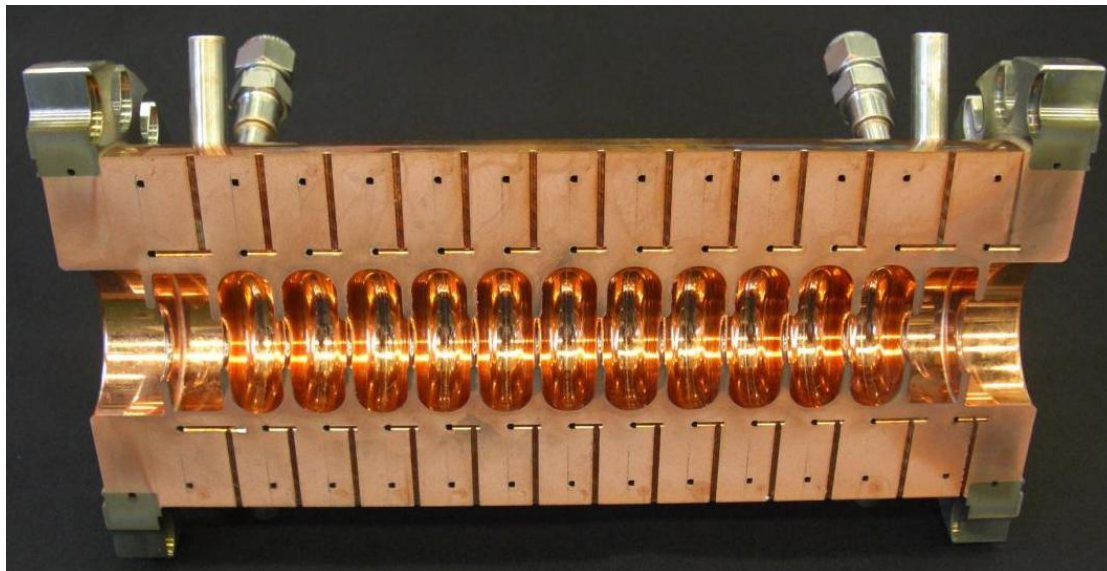


LL RF measurements

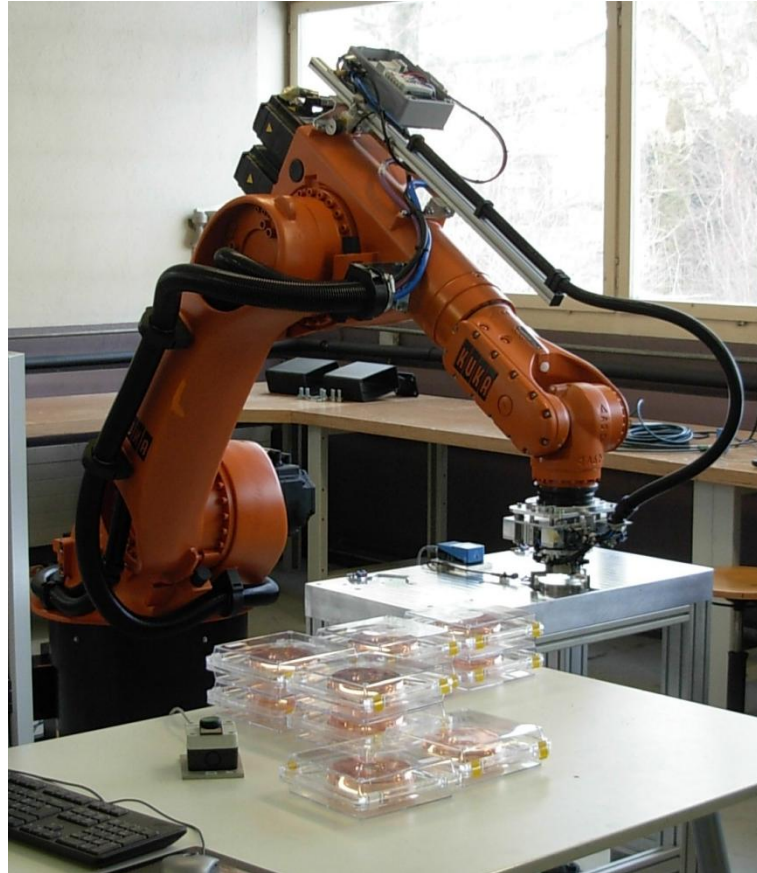
Results C-band short prototype structure high power tests

Test structure #	# cells	Ø iris	bake-out	P _{in}	E _{acc}	T _{pulse}	rep. rate	break-down prob.	β_{FN}
		mm		MW	MV/m	μ s	Hz		
1	11	14.6	yes	43	33.5	0.35	10	$8 \cdot 10^{-7}$	68
2	11	14.6	no	50	36.0	1.0	100	$3 \cdot 10^{-6}$	68
3*	11	11.2	no	49	57.0	0.8	100	$1 \cdot 10^{-6}$	45
SwissFEL nominal	113	14.6→11.2	no	28	28.0	0.35	100	$1 \cdot 10^{-8}$	

*Test in progress



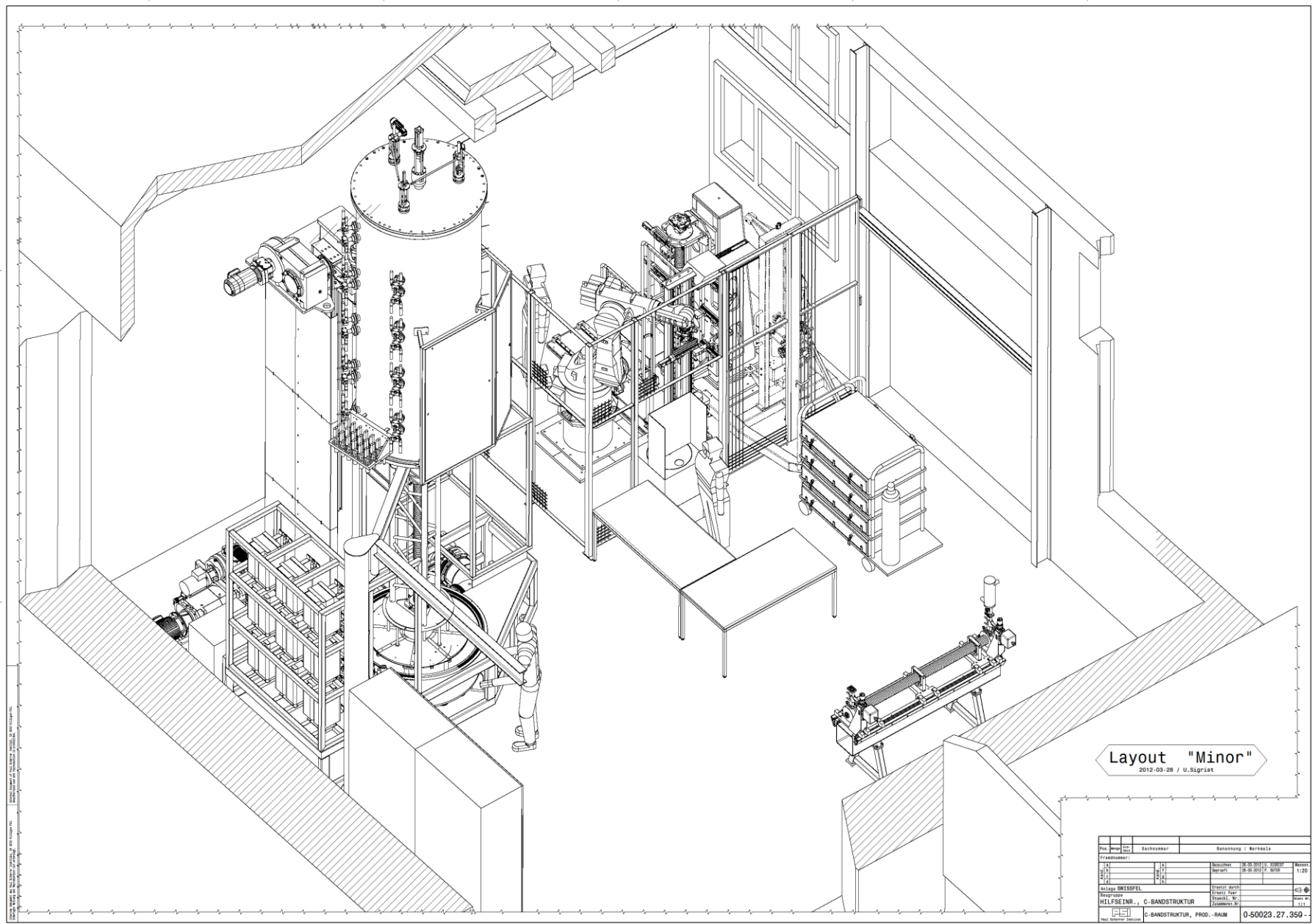
RF structure assembly robot



New brazing furnace for 2m linac structures



Assembly & brazing set-up for series production



Pos.	Bezeichnung	Material	Maßstab
1	Flansch	St 30.4	1:20
2	Flansch	St 30.4	1:20
3	Flansch	St 30.4	1:20
4	Flansch	St 30.4	1:20
5	Flansch	St 30.4	1:20
6	Flansch	St 30.4	1:20
7	Flansch	St 30.4	1:20
8	Flansch	St 30.4	1:20
9	Flansch	St 30.4	1:20
10	Flansch	St 30.4	1:20
11	Flansch	St 30.4	1:20
12	Flansch	St 30.4	1:20
13	Flansch	St 30.4	1:20
14	Flansch	St 30.4	1:20
15	Flansch	St 30.4	1:20
16	Flansch	St 30.4	1:20
17	Flansch	St 30.4	1:20
18	Flansch	St 30.4	1:20
19	Flansch	St 30.4	1:20
20	Flansch	St 30.4	1:20
21	Flansch	St 30.4	1:20
22	Flansch	St 30.4	1:20
23	Flansch	St 30.4	1:20
24	Flansch	St 30.4	1:20
25	Flansch	St 30.4	1:20
26	Flansch	St 30.4	1:20
27	Flansch	St 30.4	1:20
28	Flansch	St 30.4	1:20
29	Flansch	St 30.4	1:20
30	Flansch	St 30.4	1:20
31	Flansch	St 30.4	1:20
32	Flansch	St 30.4	1:20
33	Flansch	St 30.4	1:20
34	Flansch	St 30.4	1:20
35	Flansch	St 30.4	1:20
36	Flansch	St 30.4	1:20
37	Flansch	St 30.4	1:20
38	Flansch	St 30.4	1:20
39	Flansch	St 30.4	1:20
40	Flansch	St 30.4	1:20
41	Flansch	St 30.4	1:20
42	Flansch	St 30.4	1:20
43	Flansch	St 30.4	1:20
44	Flansch	St 30.4	1:20
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53	Flansch	St 30.4	1:20
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96	Flansch	St 30.4	1:20
97	Flansch	St 30.4	1:20
98	Flansch	St 30.4	1:20
99	Flansch	St 30.4	1:20
100	Flansch	St 30.4	1:20

Undulator lines

MOPD37,

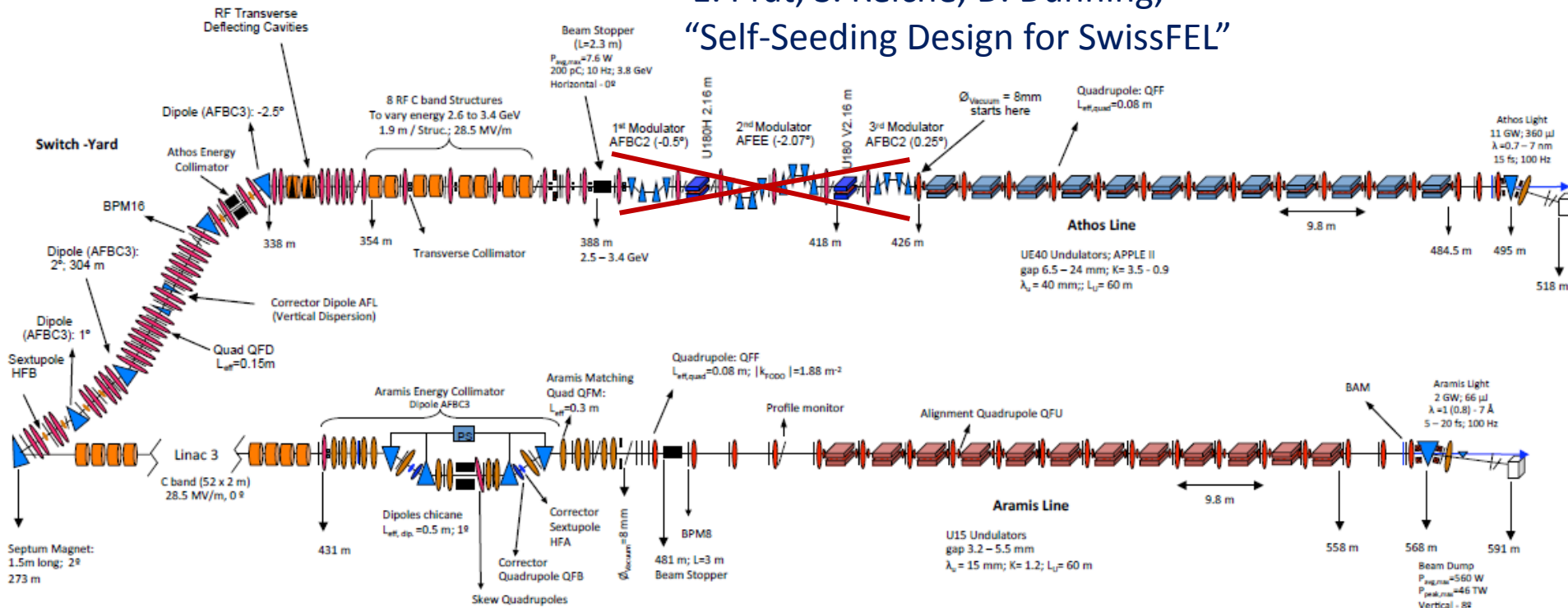
N. Milas, S. Reiche,

“Switchyard Design: Athos”

TUPD21

E. Prat, S. Reiche, D. Dunning,

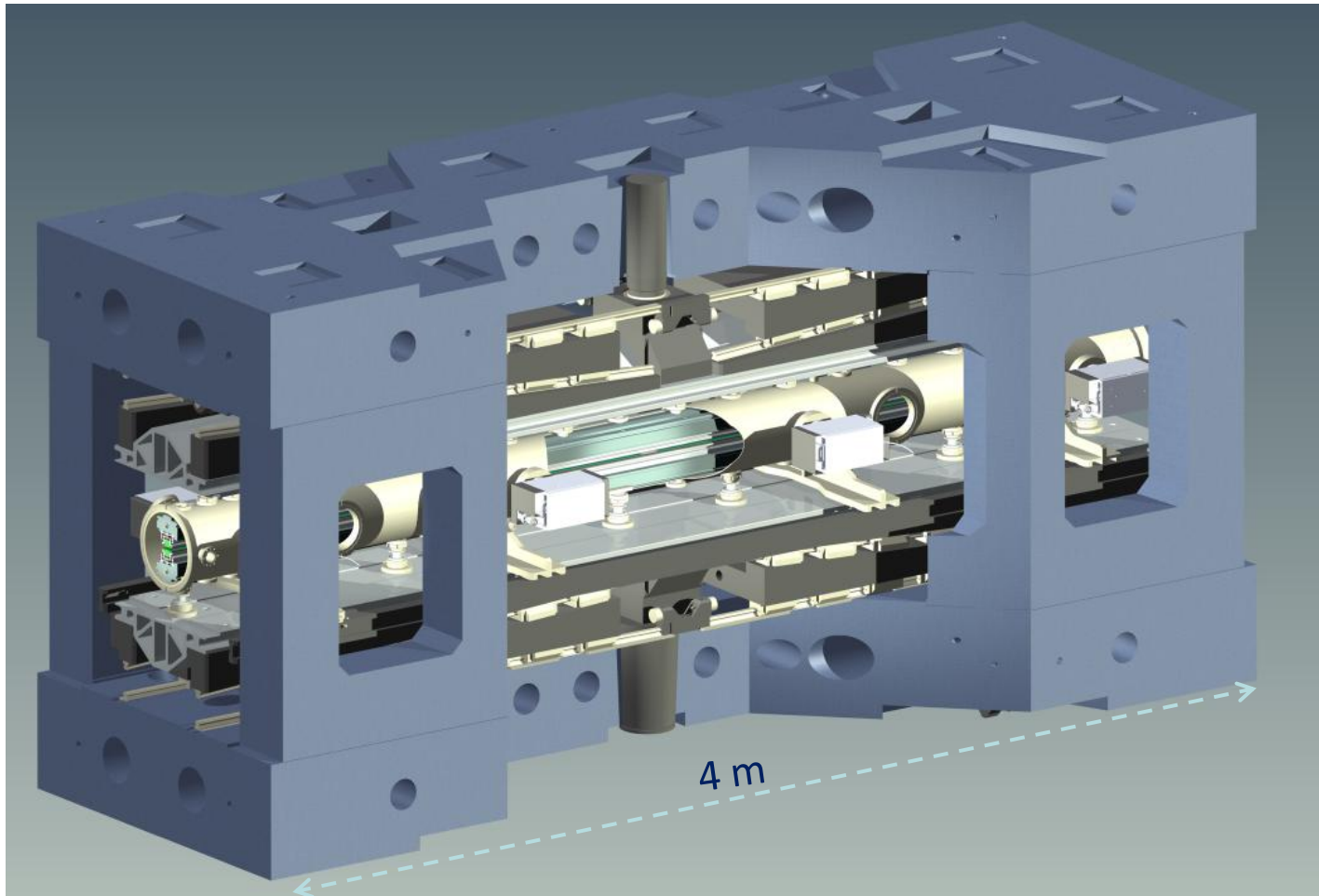
“Self-Seeding Design for SwissFEL”



THPD19,

R. Ganter, M. Aiba, H. Braun, M. Calvi, A. Fuchs, E. Hohmann, R. Ischebeck, H. Joehri, B. Keil, N. Milas, M. Negrazus, S. Reiche, S. Sanfilippo, T. Schmidt, P. Wiegand,
“Technical Overview of SwissFEL Undulator Section”

U15 in-vacuum undulator for SwissFEL

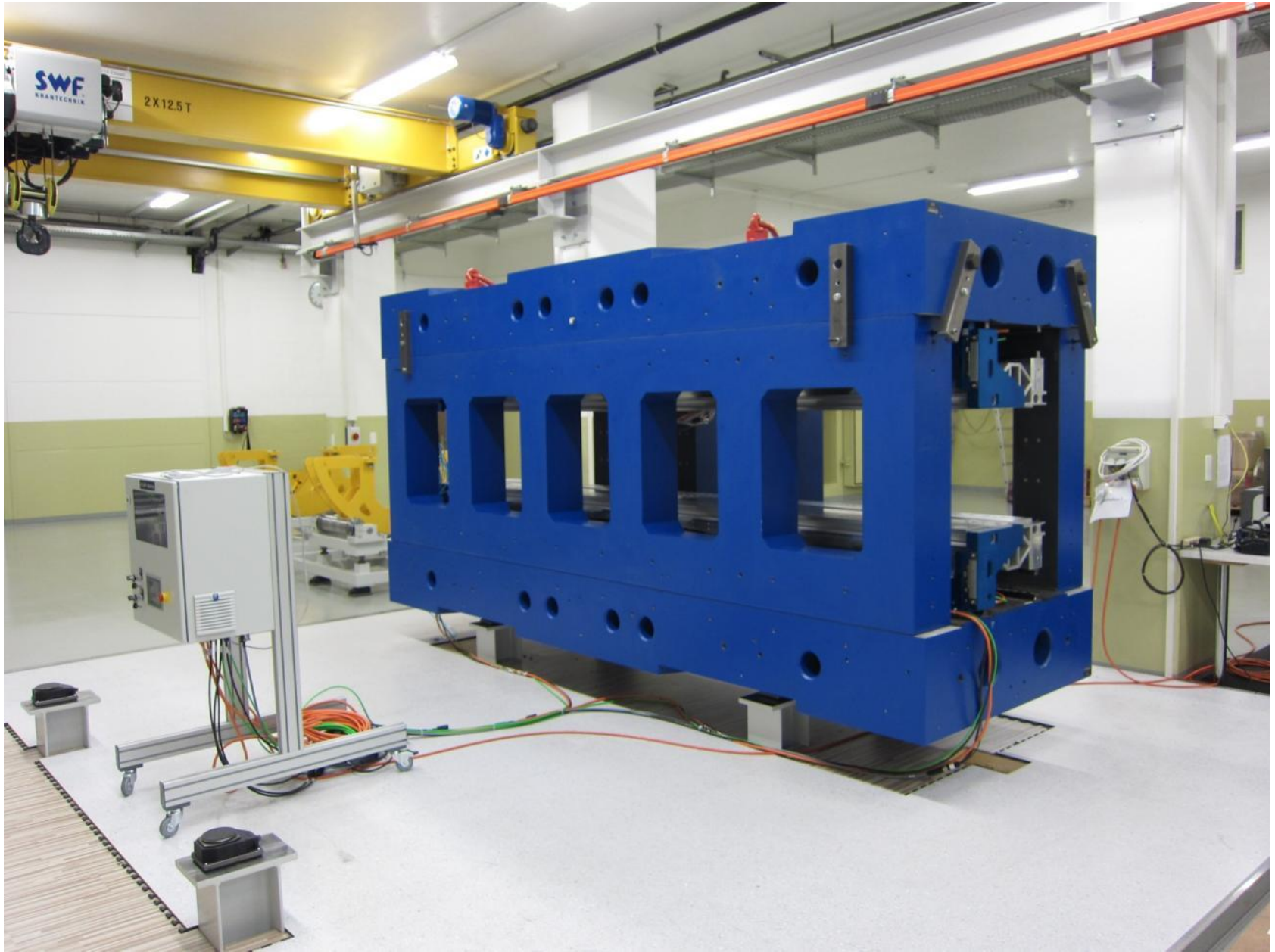


THPD64,

T. Schmidt, M. Calvi,

“SwissFEL U15 Prototype Design and First Results”

Undulator frame at Daetwyler facilities



Magnet array

short prototype



THPD63

M. Calvi, T. Schmidt,

“SwissFEL U15 Magnet Assembly: First Experimental Results”

Aramis Beamline

100.9 m
100.5 m
95 m
90 m

v: 0 mrad

Large offset
Monochromator

AR2: Offset Mirror 2
H: 0 mrad
V: -6 mrad

4 Bounce Mono-
or
X-ray Delay Li

4 Bounce
Monochromator

Channel cut
Monochromator

AR1
H: -12 mrad
V: 0 mrad

AR2
H: 0 mrad
V: 6 mrad

AR3
H: 8 mrad
V: 0 mrad

Beam stopper

Collimator

Beam profile Monitor
Intensity and
position monitor

120 mm 76 mm

AR2: Offset Mirror 1
H: 0 mrad
V: 6 mrad

AR3: Offset Mirror 2
H: 4 mrad
V: 0 mrad

AR1: Offset Mirror 2
H: -6 mrad
V: 0 mrad

AR3: Offset Mirror 1
H: 4 mrad
V: 0 mrad

Vacuum valve

AR1: Offset Mirror 1
H: -6 mrad
V: 0 mrad

50 m



ARAMIS Endstations

2017

ES-A

Multi-purpose
Pump-Probe

2017

ES-B

Pump-Probe
Crystallography

2018

ES-C

Coherent
Diffraction
Imaging

201X

ES-O

“Others”

NOT DEFINITIVE

Mirrors

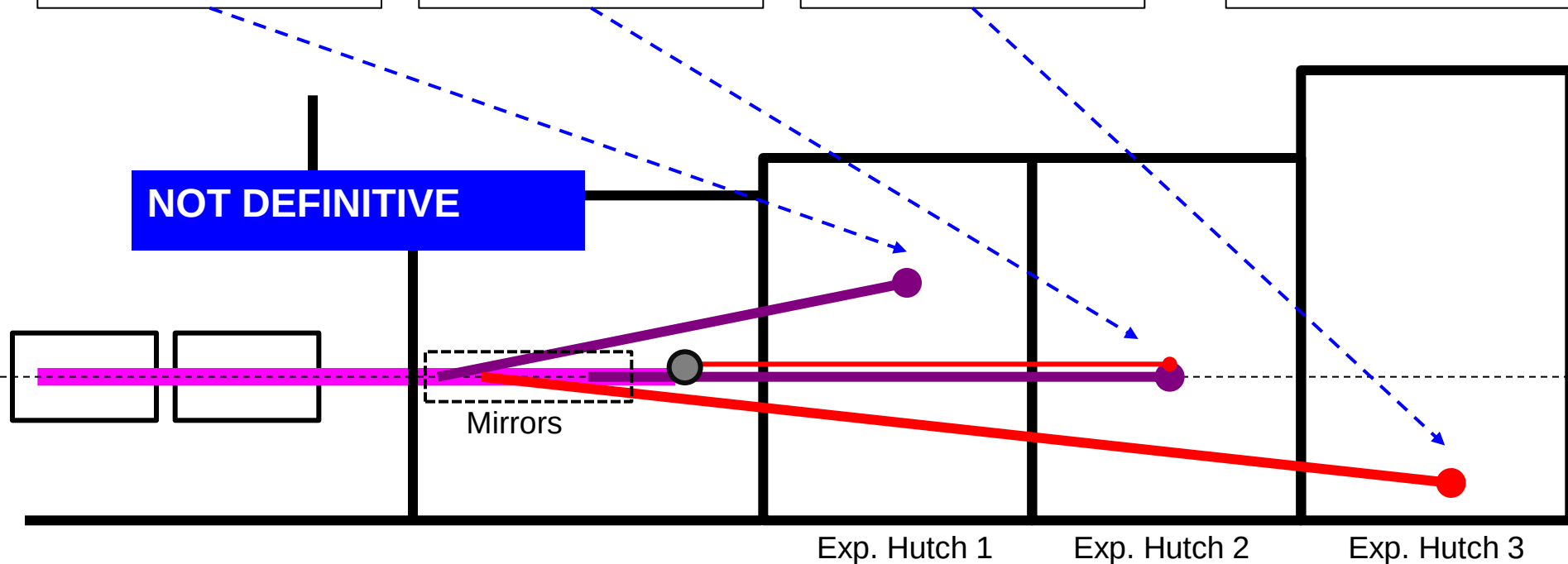
Exp. Hutch 1

Exp. Hutch 2

Exp. Hutch 3

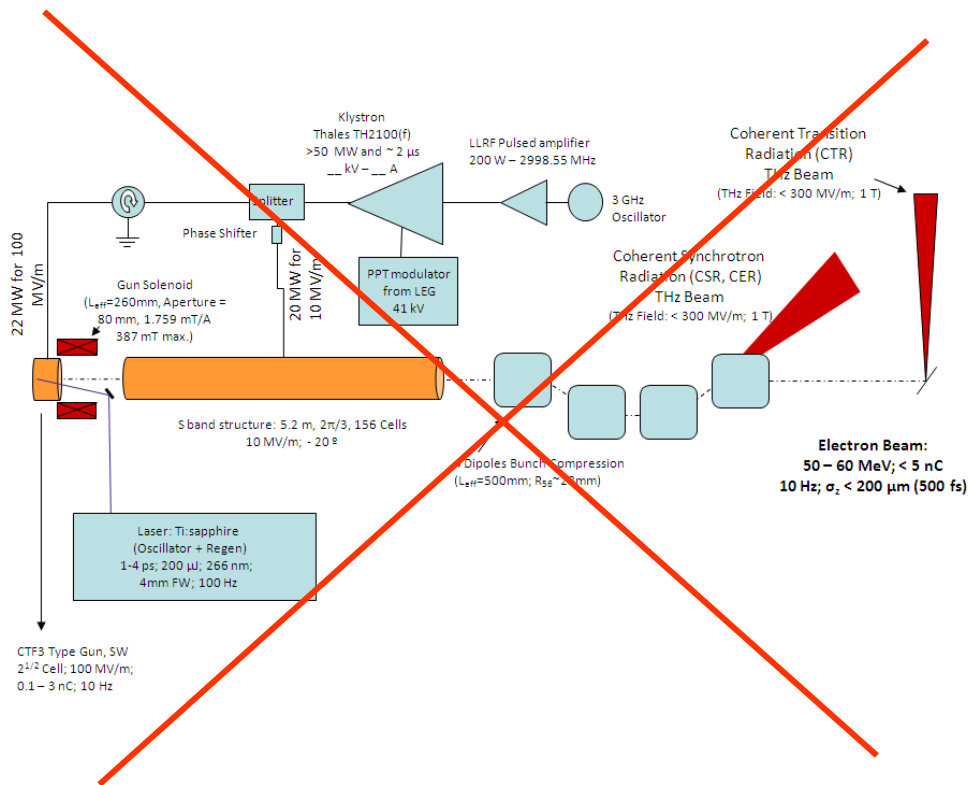


Double crystal monochromator



High power THz source for experiments

Laser based instead of accelerator based



Strong-field single-cycle THz pulses generated in an organic crystal

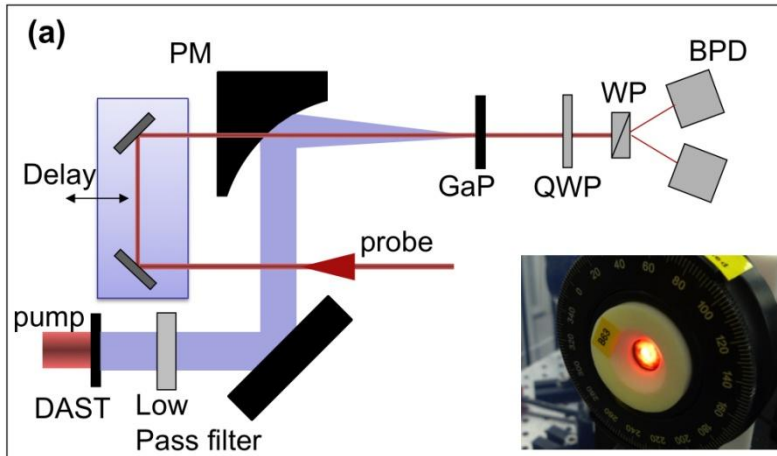
Christoph P. Hauri,^{1,2,a)} Clemens Ruchert,¹ Carlo Vicario,¹ and Fernando Ardana^{1,2}

¹Paul Scherrer Institute, 5232 Villigen, Switzerland

²Physics Department, Ecole Polytechnique Fédérale de Lausanne, 1013 Lausanne, Switzerland

DAST : 4-N,N-dimethylamino-4'-N'methyl stilbazolium tosylate

strong optical nonlinearity, low absorption



Experimental results

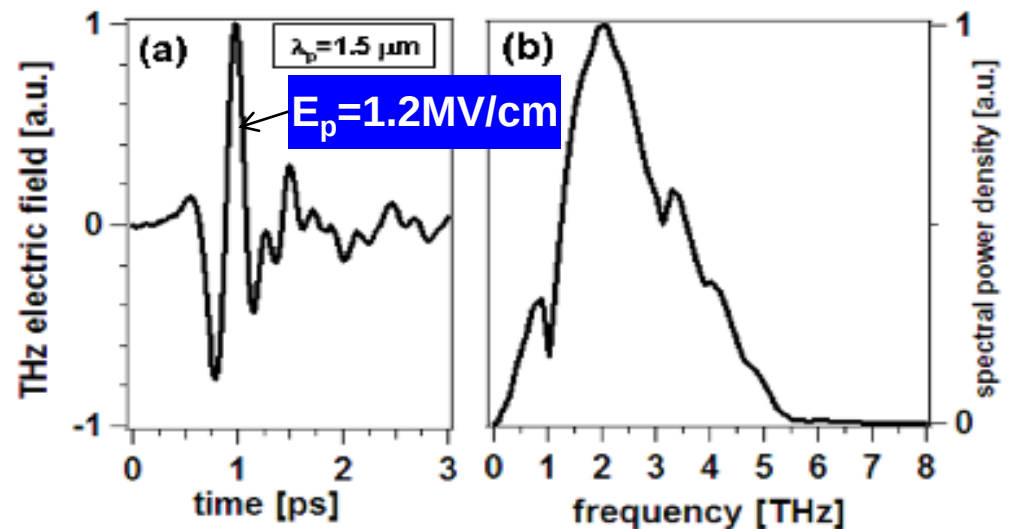
- Recorded peak E field >1.2 MV/cm, $B > 0.35$ T
- spectrum <5 THz centered at $\nu_c = 2$ THz
- close to single cycle
- THz pulse energy up to 45 μ J
- Good shot-to-shot energy stability (rms 1%)
- Energy up-scaling feasible (larger crystal, more pump energy)

IR-THz phase matching require
1.2-1.5 μ m pump (OPA)

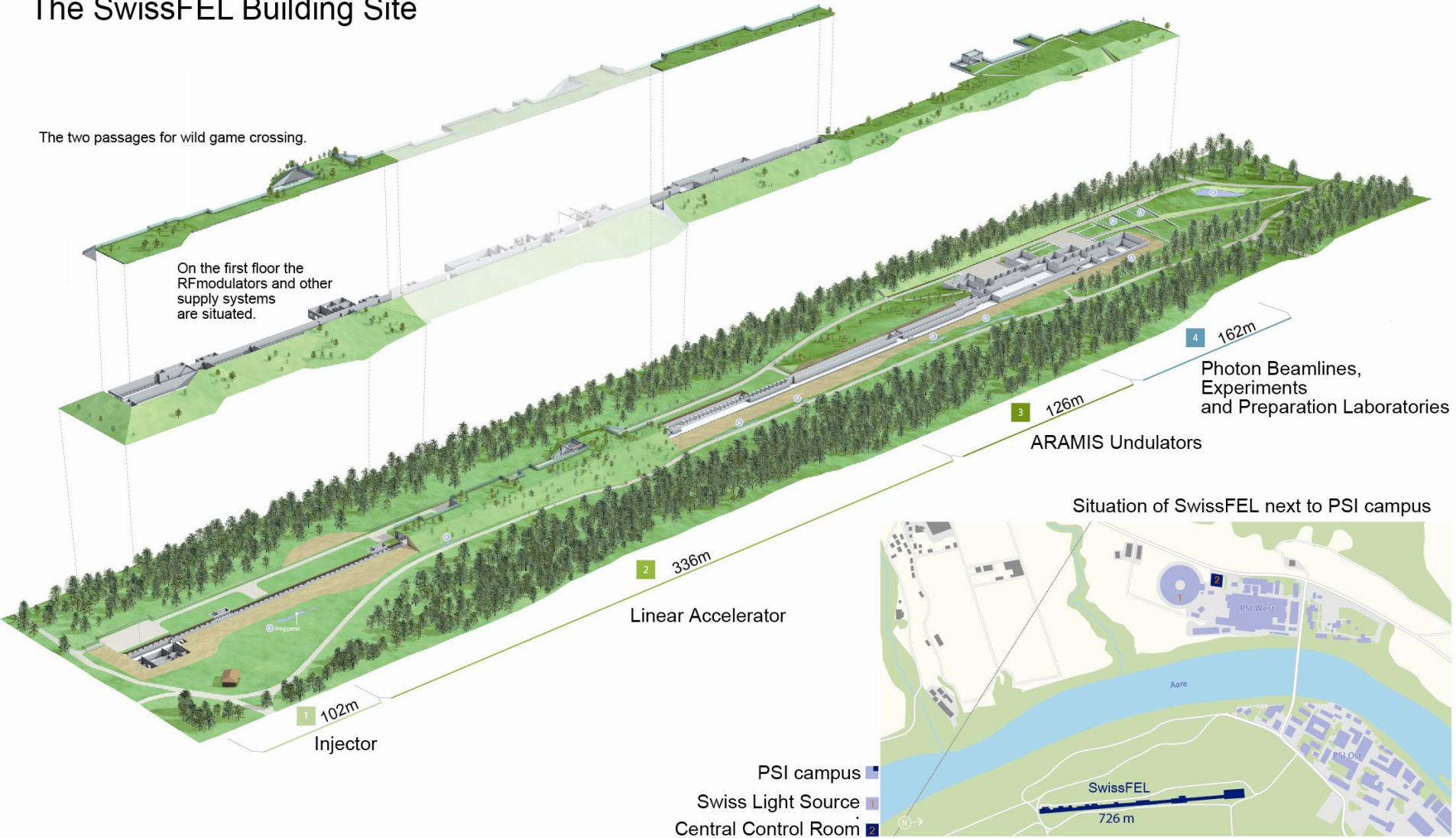
FROA04,

**C. Hauri, F. Ardana-Lamas, M. Divall-Csatari,
A. Trisorio, C. Vicario, C. Ruchert**

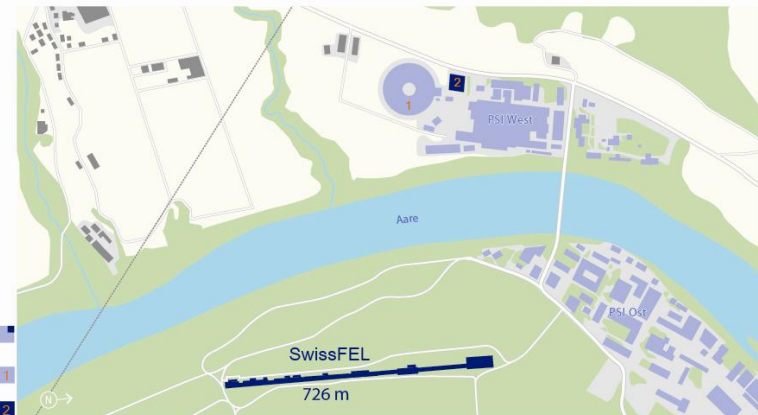
*“New Laser Developments for
Pump-probe Experiments at SwissFEL”*



The SwissFEL Building Site



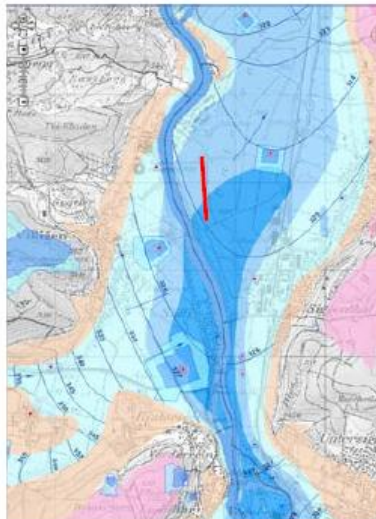
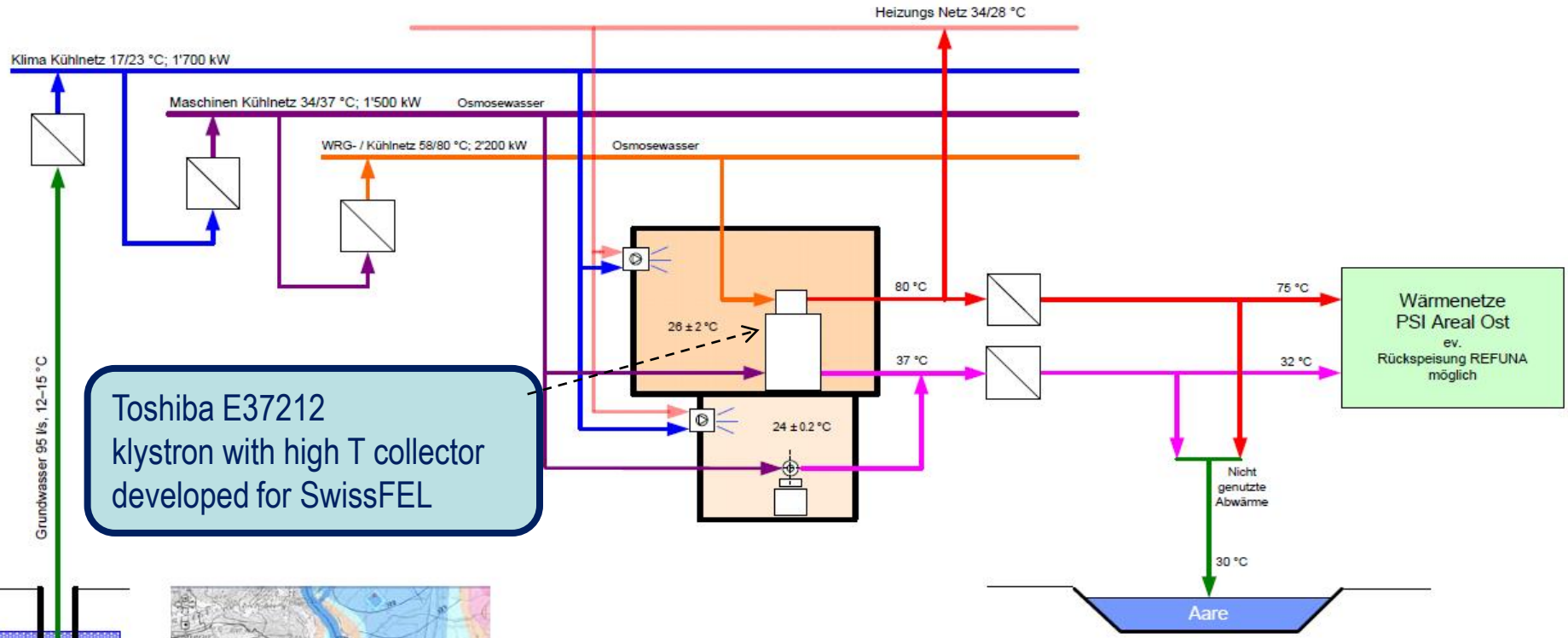
Situation of SwissFEL next to PSI campus



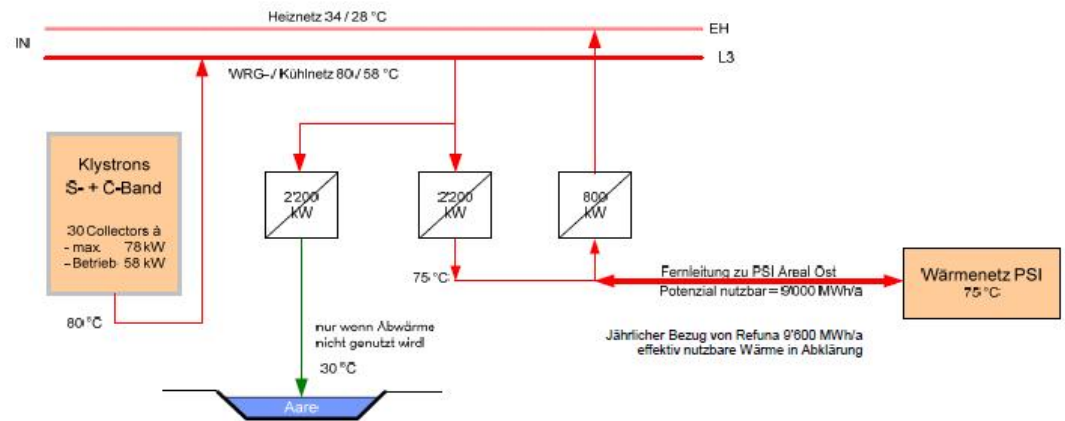
Ground water well for cooling water, first civil work for SwissFEL



Energy recovery for SwissFEL



Grundwasserkarte



Wärmerückgewinnung

MOOC02

S. Reiche, E. Prat, "Growth Rates and Coh. Properties of FODO-lattice based X-ray Free Electron Lasers"

MOPD36

F. Le Pimpec, A. Adelman, S. Reiche, R. Zennaro, B. Grigoryan, "Dark Current Studies for SwissFEL"

MOPD37

N. Milas, S. Reiche, "Switchyard Design: Athos"

TUPD21

E. Prat, S. Reiche, D. Dunning, "-Seeding Design for SwissFEL"

TUPD27

M. Aiba, M. Böge, "Beam based Alignment of X-FEL Undulator Section Utilizing Corrector Pattern"

TUPD28,

B. Beutner, "Bunch Compression Layout and Longitudinal Operation Modes for the SwissFEL Aramis Line"

THPD19

R. Ganter et al., "Technical Overview of SwissFEL Undulator Section"

THPD63

M. Calvi, T. Schmidt, "SwissFEL U15 Magnet Assembly: First Experimental Results"

THPD64

T. Schmidt, M. Calvi, "SwissFEL U15 Prototype Design and First Results"

FROA04

C. Hauri, "New Laser Developments for Pump-probe Experiments at SwissFEL"

New release of design report, April 2012

PAUL SCHERRER INSTITUT PSI	
	SwissFEL Conceptual Design Report
	
PSI Bericht Nr. 10-04 April 2012	

PDF at

www.psi.ch/SwissFEL